



Patent
62478-6600

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Yoshiki Sasaki et al.

Serial No.: 09/786,958

Filed: July 2, 2001

For: SEALING METHOD AND
APPARATUS FOR
MANUFACTURING
HIGH-PERFORMANCE GAS
DISCHARGE PANEL

Patent Examiner: Ha, Nguyen T.

Group Art Unit: 2831

July 10, 2003

Irvine, California 92614

#7/ELECTION/B
DEVANS
7-23-03

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

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Dear Sir:

In response to the Restriction Requirement of June 10, 2003, please amend the above-identified Application as follows:

COPY



NAK1-BO17

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Yoshiki Sasaki et al.

Serial No.:

Filed:

For: SEALING METHOD AND APPARATUS FOR
MANUFACTURING HIGH-PERFORMANCE
GAS DISCHARGE PANEL

Examiner:

Group Art Unit:

Irvine, CA 92614

March 12, 2001

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

Prior to an examination on the merits of the above-identified application, please enter the following amendments:

IN THE CLAIMS:

Please amend the claims as follows:

- 1 4. (Amended) The gas discharge panel production method of Claim 2, wherein
- 2 in the surrounding unit forming step, a connection path which connects inside of the
- 3 surrounding unit to outside of the surrounding unit is formed in the surrounding unit, and
- 4 in the pressure adjustment sub-step, gas is exhausted from inside of the surrounding unit
- 5 to outside of the surrounding unit via the connection path.